Group Art Unit: 2825

Examiner: L. Malsawma

Docket No.: M4065.0111/P111-A (PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Howard E. Rhodes, et al

Application No.: 09/780,390

Filed: February 12, 2001

For: OPTIMIZED LOW LEAKAGE DIODES,

INCLUDING PHOTODIODES

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<u>AMENDMENT</u>

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Box Non-Fee Amendment Commissioner for Patents Washington, DC 20231 **TECHNOLOGY CENTER 2800**

Dear Sir:

In response to the Office Action dated February 4, 2003 (Paper No. 7), please amend the above-identified U.S., patent application as follows:

In the claims:

Please rewrite claims 1, 16-23, 28, 50 and 67 as follows:

1. (Amended) A diode, said diode comprising:

an isolation region formed in a substrate;

a first doped active layer of a first conductivity type formed in said substrate, wherein said doped active layer is spaced apart from said isolation region;

a second doped active layer of a second conductivity type in contact with said first doped active layer, the contact of said first and second active layers forming a p-n junction; and

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